

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Hayashi et al.
Appl. No. : 10/561,830
Filed : December 22, 2005
For : POSITIVE RESIST
COMPOSITION AND METHOD
OF FORMING RESIST PATTERN
USING SAME
Examiner : Eoff, Anca
Group Art Unit : 1795

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **February 2, 2010**, please consider the following amendments and remarks:

Amendments to the claims are reflected in **the listing of claims** which begins on page 2 of this paper.

Remarks/Arguments begin on page 4 of this paper.